

Subt E<sup>1</sup>

## REPLACEMENT CLAIMS

37. (three times amended) A capacitor comprising:

a first electrode and a second electrode, wherein at least one of said first and second electrodes is formed of a material selected from the group consisting of Ru, Rh, Pd, Os, Ir and Pt;

a dielectric provided between said electrodes; and

wherein at least one of said first and second electrodes has a thickness of about 50 Angstroms to about 1000 Angstroms and is formed of a continuous platinum group metal formed in the presence of both oxygen and nitrous oxide at a predetermined ratio with a combined flow rate in the range of about 1500 sccm to about 2500 sccm.

Subt E<sup>2</sup>

41. (three times amended) A capacitor comprising:

a first electrode and a second electrode, wherein at least one of said first and second electrodes is formed of a material selected from the group consisting of Ru, Rh, Pd, Os, Ir and Pt;

a dielectric provided between said electrodes; and

wherein at least one of said first and second electrodes has a thickness of about 500 Angstroms to about 700 Angstroms and is a smooth and continuous platinum electrode formed by depositing platinum in a CVD deposition chamber in the presence of both oxygen and nitrous oxide at a predetermined temperature and at a pressure of from about 10 to about 1000 Torr.